

Notice of Allowability	Application No.	Applicant(s)	
	09/779,123	SETHURAMAN ET AL.	
	Examiner	Art Unit	
	Hsien-Ming Lee	2823	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address--

All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. **THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS.** This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.

1. This communication is responsive to 7/19/2004.
2. The allowed claim(s) is/are 1-4, 7-12, 15 and 17-27.
corrected
3. The drawings filed on 08 October 2002 are accepted by the Examiner.
4. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
 - a) All
 - b) Some*
 - c) None
 of the:
 1. Certified copies of the priority documents have been received.
 2. Certified copies of the priority documents have been received in Application No. _____.
 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)).

* Certified copies not received: _____.

Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.
THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.

5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.
6. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.
 - (a) including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached
 - 1) hereto or 2) to Paper No./Mail Date _____.
 - (b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date _____.
7. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.

Attachment(s)

1. Notice of References Cited (PTO-892)
2. Notice of Draftsperson's Patent Drawing Review (PTO-948)
3. Information Disclosure Statements (PTO-1449 or PTO/SB/08),
Paper No./Mail Date _____
4. Examiner's Comment Regarding Requirement for Deposit
of Biological Material
5. Notice of Informal Patent Application (PTO-152)
6. Interview Summary (PTO-413),
Paper No./Mail Date _____
7. Examiner's Amendment/Comment
8. Examiner's Statement of Reasons for Allowance
9. Other _____.

HSIEN-MING LEE
PRIMARY EXAMINER
Lee

9/1/2004

DETAILED ACTION

Remarks

1. The objection to claims 1, 9 and 17 is withdrawn.
2. The corrected drawings filed 10/8/2002 have been approved.

Allowable Subject Matter

3. Claims 1-4, 7-12, 15 and 17-27 are allowed.
4. The following is an examiner's statement of reasons for allowance:

The closest prior art of record, Jaso et al. to US 6,093,631, teaches a method, comprising:

- etching a plurality of laterally spaced dummy trenches 20 into a dielectric layer 14 between a first trench 15d and a series of second trenches 15a/15b/15c (Fig. 11B);
- filling the dummy trenches 20 and the first 15d and the series of second trenches 15a/15b/15c with a conductive material 16 (i.e. copper or aluminum or tungsten)(Fig. 11C and col.7, lines 3-7); and
- polishing the conductive material 16 to form dummy conductors in the dummy trenches 20 and interconnect in the first trench 15d and the series of second trenches 15a/15b/15c.

In contrast, Jaso et al. at least neither teach nor suggest that the *second* trenches is a relatively narrow compared to the first trench and that polishing the conductive material by applying a liquid substantially *free of particulate matter* between an abrasive polishing surface and the conductive material.

Therefore, the instant invention is neither anticipated nor rendered obvious over the prior art of record.

5. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hsien-Ming Lee whose telephone number is 571-272-1863. The examiner can normally be reached on Tuesday-Thursday (8:00 ~ 6:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

HSIEN-MING LEE
PRIMARY EXAMINER
[Signature]

Hsien-Ming Lee
Primary Examiner
Art Unit 2823

Sep. 21, 2004

9/21/2004